## What is claimed is:

- 1. A four-transistor random access memory cell
   2 comprising:
- a first transistor of a first conductivity type having
- a gate coupled to a word line and a source
- 5 coupled to a bit line;
- a second transistor of the first conductivity type
- 7 having a gate coupled to a drain of the first
- 8 transistor and a source coupled to receive a
- 9 first voltage;
- 10 a third transistor of a second conductivity type having
- a gate coupled to a drain of the second
- transistor, a source coupled to receive a second
- 13 voltage and a drain coupled to the drain of the
- first transistor; and
- a fourth transistor of the second conductivity type
- 16 having a gate coupled to the drain of the first
- 17 transistor, a source coupled to receive the
- 18 second voltage and a drain coupled to the drain
- of the second transistor.
- 1 2. The four-transistor random access memory cell as
- 2 in claim 1, wherein the first transistor further comprises a
- 3 bulk coupled to receive a third voltage.
- 1 3. The four-transistor random access memory cell as
- 2 in claim 2, wherein the first voltage is Vdd, the second
- 3 voltage is a ground voltage and the third voltage is  $V_{pp}$
- 4 higher than V<sub>dd</sub>.

- 1 4. The four-transistor random access memory cell as
- 2 in claim 2, wherein the first voltage is  $V_{dd}$ , the second
- 3 voltage is  $V_{bb}$  and the third voltage is  $V_{pp}$  higher than  $V_{dd}$ .
- 1 5. The four-transistor random access memory cell as
- 2 in claim 1, wherein the second transistor further comprises
- 3 a bulk coupled to receive a third voltage.
- 1 6. The four-transistor random access memory cell as
- 2 in claim 5, wherein the first voltage is Vdd, the second
- 3 voltage is a ground voltage and the third voltage is  $V_{PP}$
- 4 higher than V<sub>dd</sub>.
- 1 7. The four-transistor random access memory cell as
- 2 in claim 5, wherein the first voltage is  $V_{dd}$ , the second
- 3 voltage is  $V_{bb}$  and the third voltage is  $V_{pp}$  higher than  $V_{dd}$ .
- 1 8. The four-transistor random access memory cell as
- 2 in claim 1, wherein the first transistor further comprises a
- 3 bulk coupled to receive the first voltage.
- 1 9. The four-transistor random access memory cell as
- 2 in claim 8, wherein the first voltage is  $V_{dd}$  and the second
- 3 voltage is a ground voltage.
- 1 10. The four-transistor random access memory cell as
- 2 in claim 8, wherein the first voltage is  $V_{dd}$  and the second
- 3 voltage is  $V_{bb}$ .
- 1 11 The four-transistor random access memory cell as
- 2 in claim 1, wherein the second transistor further comprises
- 3 a bulk coupled to receive the first voltage.

- 1 12. The four-transistor random access memory cell as
- 2 in claim 11, wherein the first voltage is Vdd and the second
- 3 voltage is a ground voltage.
- 1 13. The four-transistor random access memory cell as
- 2 in claim 11, wherein the first voltage is  $V_{dd}$  and the second
- 3 voltage is  $V_{bb}$ .
- 1 14. The four-transistor random access memory cell as
- 2 in claim 1, wherein the first and second conductivity types
- 3 are respectively P and N type.
- 1 15. A random access memory cell comprising:
- a first transistor of a first conductivity type having
- a gate coupled to a word line and a source
- 4 coupled to a bit line;
- 5 a second transistor of a second conductivity type
- 6 having a source coupled to receive a second
- 7 voltage and a drain coupled to the drain of the
- 8 first transistor;
- 9 a diode having an anode coupled to the drain of the
- 10 first transistor and a cathode coupled to receive
- a first voltage; and
- 12 an inverter having an input terminal coupled to the
- drain of the first transistor and an output
- 14 terminal coupled to a gate of the second
- transistor.
- 1 16. The random access memory cell as in claim 15,
- 2 wherein the inverter comprises:

- a third transistor of the first conductivity type
- 4 having a gate coupled to the drain of the first
- 5 transistor and a source coupled to receive the
- first voltage; and
- 7 a fourth transistor of the second conductivity type
- 8 having a gate coupled to the drain of the first
- 9 transistor, a source coupled to receive the
- second voltage and a drain coupled to the drain
- of the third transistor.
- 1 17. The random access memory cell as in claim 16,
- 2 wherein the first and third transistor each comprise a bulk
- 3 coupled to receive a third voltage.
- 1 18. The random access memory cell as in claim 17,
- 2 wherein the first voltage is  $V_{dd}$ , the second voltage is a
- 3 ground voltage and the third voltage is  $V_{PP}$  higher than  $V_{dd}$ .
- 1 19. The random access memory cell as in claim 17,
- 2 wherein the first voltage is  $V_{dd}$ , the second voltage is  $V_{bb}$
- 3 and the third voltage is  $V_{PP}$  higher than  $V_{dd}$ .
- 1 20. The random access memory cell as in claim 16,
- 2 wherein each of the first and third transistors comprises a
- 3 bulk coupled to receive the first voltage.
- 1 21. The random access memory cell as in claim 20,
- 2 wherein the first voltage is  $V_{dd}$  and the second voltage is a
- 3 ground voltage.

The random access memory cell as in claim 20,

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2 wherein the first voltage is  $V_{dd}$  and the second voltage is 3  $V_{bb}$ . 1 The random access memory cell as in claim 16, 2 wherein the diode is formed by a junction between the bulk and drain of the first transistor. 3 1 A memory device comprising: 2 a plurality of memory cells wherein data is read from 3 . and written into each of the memory cells through bit lines by control signals on word lines, each 5 of the memory cells comprising: a first transistor of a first conductivity type 6 7 having a gate coupled to one of the word 8 lines and a source coupled to one of the bit 9 lines; 10 a second transistor of the first conductivity type 11 having a gate coupled to a drain of the 12 first transistor and a source coupled to 13 receive a first voltage; 14 a third transistor of a second conductivity type 15 having a gate coupled to a drain of the 16 second transistor, a source coupled to 17 receive a second voltage and a drain coupled 18 to the drain of the first transistor; and 19 a fourth transistor of the second conductivity 20 type having a gate coupled to the drain of 21 the first transistor, a source coupled to 22 receive the second voltage and a drain

- coupled to the drain of the second
- 24 transistor.
- 1 25. The memory device as in claim 24, wherein the
- 2 first transistor further comprises a bulk coupled to receive
- 3 a third voltage.
- 1 26. The memory device as in claim 25, wherein the
- 2 first voltage is  $V_{dd}$ , the second voltage is a ground voltage
- 3 and the third voltage is  $V_{PP}$  higher than  $V_{dd}$ .
- 1 27. The memory device as in claim 25, wherein the
- 2 first voltage is  $V_{dd}$ , the second voltage is  $V_{bb}$  and the third
- 3 voltage is  $V_{PP}$  higher than  $V_{dd}$ .
- 1 28. The memory device as in claim 24, wherein the
- 2 second transistor further comprises a bulk coupled to
- 3 receive the third voltage.
- 1 29. The memory device as in claim 28, wherein the
- 2 first voltage is  $V_{dd}$ , the second voltage is a ground voltage
- 3 and the third voltage is Vpp higher than Vdd.
- 1 30. The memory device as in claim 28, wherein the
- 2 first voltage is  $V_{dd}$ , the second voltage is  $V_{bb}$  and the third
- 3 voltage is  $V_{pp}$  higher than  $V_{dd}$ .
- 1 31. The memory device as in claim 24, wherein the
- 2 first transistor further comprises a bulk coupled to receive
- 3 the first voltage.

- 1 32. The memory device as in claim 31, wherein the
- 2 first voltage is  $V_{dd}$ , the second voltage is a ground voltage
- 3 and the third voltage is  $V_{PP}$  higher than  $V_{dd}$ .
- 1 33. The memory device as in claim 31, wherein the
- 2 first voltage is  $V_{dd}$ , the second voltage is  $V_{bb}$  and the third
- 3 voltage is  $V_{PP}$  higher than  $V_{dd}$ .
- 1 34. The memory device as in claim 24, wherein and the
- 2 second transistor further comprises a bulk coupled to
- 3 receive the first voltage.
- 1 35. The memory device as in claim 34, wherein the
- 2 first voltage is  $V_{dd}$ , the second voltage is a ground voltage
- 3 and the third voltage is  $V_{PP}$  higher than  $V_{dd}$ .
- 1 36. The memory device as in claim 34, wherein the
- 2 first voltage is  $V_{dd}$ , the second voltage is  $V_{bb}$  and the third
- 3 voltage is  $V_{pp}$  higher than  $V_{dd}$ .
- 1 37. The memory device as in claim 24, wherein the
- 2 first and second conductivity types are P and N type
- 3 respectively.
- 38. A memory device comprising:
- 2 a plurality of memory cells wherein data is read from
- and written into each of the memory cells through
- 4 bit lines by control signals on word lines, each
- of the memory cells comprising:
- 6 a first transistor of a first conductivity type having
- a gate coupled to a word line and a source
- 8 coupled to a bit line;

a second transistor of a second conductivity type 9 10 having a source coupled to receive a second voltage and a drain coupled to the drain of the 11 12 first transistor; 13 a diode having an anode coupled to the drain of the first transistor and a cathode coupled to receive 14 15 a first voltage; and 16 an inverter having an input terminal coupled to the drain of the first transistor and an output 17 18 terminal coupled to a gate of the second 19 transistor. 1 The memory device as in claim 38, wherein the 2 inverter further comprises: 3 a third transistor of the first conductivity type having a gate coupled to the drain of the first 5 transistor and a source coupled to receive the 6 first voltage; and 7 a fourth transistor of the second conductivity type 8 having a gate coupled to the drain of the first 9 transistor, a source coupled to receive the 10 second voltage and a drain coupled to the drain of the third transistor. 11 1 The memory device as in claim 39, wherein the 2 first and third transistors each comprise a bulk coupled to 3 receive a third voltage. 1 The memory device as in claim 40, wherein the first voltage is Vdd, the second voltage is a ground voltage 2 and the third voltage is VPP higher than Vdd.

- 1 42. The memory device as in claim 40, wherein the
- 2 first voltage is Vdd, the second voltage is Vbb and the
- 3 third voltage is VPP higher than Vdd.
- 1 43. The memory device as in claim 39, wherein the
- 2 first and third transistors each comprise a bulk coupled to
- 3 receive the first voltage.
- 1 44. The memory device as in claim 43, wherein the
- 2 first voltage is Vdd and the second voltage is a ground
- 3 voltage.
- 1 45. The memory device as in claim 39, wherein the
- 2 diode is formed by a junction between the bulk and drain of
- 3 the first transistor.
- 1 46. A 4T-SRAM cell in a SRAM array having pairs of a
- 2 first and second bit line, and a first and second word line,
- 3 comprising:
- a first transistor of a first conductivity type having
- a gate coupled to one of the first word lines and
- a source coupled to one of the first bit lines;
- 7 a second transistor of the first conductivity type
- 8 having a gate coupled to a drain of the first
- 9 transistor and a source coupled to receive a
- first voltage;
- a third transistor of a second conductivity type having
- 12 a gate coupled to a drain of the second
- transistor, a source coupled to receive a second
- 14 voltage and a drain coupled to the drain of the
- first transistor; and

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- a fourth transistor of the second conductivity type
  having a gate coupled to one of the second word
  lines, a source coupled to one of the second bit
  lines and a drain coupled to the gate of the
  third transistor.
- 1 47. The 4T-SRAM cell as in claim 46, wherein bulks of 2 the first and fourth transistor are respectively coupled to 3 receive the first and second voltage.
- 1 48. The 4T-SRAM cell as in claim 46, wherein the first 2 and second conductivity types are respectively P and N type.